

REMARKS

Reconsideration of the application identified in caption, pursuant to and consistent with 37 C.F.R. §1.111 and in light of the remarks which follow, is respectfully requested.

At the outset, Applicants and Applicants' representative thank Examiner Hon of the U.S. Patent and Trademark Office for her time and consideration in participating in an interview with Applicants' representative on July 17, 2007. The Interview Summary accurately reflects the substance of the interview.

During the interview, Applicants' representative noted that U.S. Patent Application Publication No. 2001/0050741 (*Hokazono et al*) does not disclose or suggest a low refractive index layer that comprises at least one inorganic fine particle having an average particle size of 30 to 100% of the thickness of the low refractive index layer and at least one silica fine particle having a particle size of less than 25% of the thickness of the low refractive index layer, as recited in independent claim 15. At the conclusion of the interview, the Examiner agreed to withdraw the outstanding rejections based on *Hokazono et al*, and advised that any new grounds of rejection if applicable, would be presented in a non-final action. See Interview Summary.

In the Official Action, claims 15-18, 23-25, 27 and 29 stand rejected under 35 U.S.C. §103(a) as being obvious over U.S. Patent Application Publication No. 2001/0050741 (*Hokazono et al*) in view of U.S. Patent No. 5,909,314 (*Oka et al*). Claims 19 and 30 stand rejected under 35 U.S.C. §103(a) as being obvious over *Hokazono et al* in view of *Oka et al* and further in view of U.S. Patent No. 6,210,858 (*Yasuda et al*). Claims 20 and 21 stand rejected under 35 U.S.C. §103(a) as being obvious over *Hokazono et al* in view of *Oka et al* and further in view of U.S. Patent No. 6,254,973 (*Yoshida et al*). Claim 26 stands rejected under 35 U.S.C. §103(a) as being obvious over *Hokazono et al* in view of *Oka et al* and

further in view of U.S. Patent No. 6,181,400 (*Yang*). Claim 28 stands rejected under 35 U.S.C. §103(a) as being obvious over *Hokazono et al* in view of *Oka et al* and further in view of U.S. Patent No. 6,633,352 (*Yamaguchi et al*).

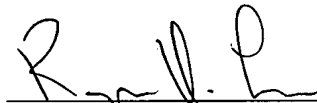
As discussed above, the Examiner has agreed to withdraw each of the above rejections, and such action is respectfully requested. Accordingly, further and favorable action in the form of a Notice of Allowance is believed to be next in order, and such action is earnestly solicited. If there are any questions concerning this paper or the application in general, the Examiner is invited to telephone the undersigned.

Respectfully submitted,

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